EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S91	0	"20020028389".pn. and electrolyte with vinylidene	US-PGPUB; USPAT	OR	ON	2009/04/09 17:22
S92	1	"20020028389".pn. and electrolyte same vinylidene	US-PGPUB; USPAT	OR	ON	2009/04/09 17:23
S93	4	"429"/$.ccls. and battery and electrolyte with vinylidene near2 flouride	US-PGPUB; USPAT	OR	ON	2009/04/09 17:24
S94	412	"429"/$.ccls. and battery and electrolyte with vinylidene near2 fluoride	US-PGPUB; USPAT	OR	ON	2009/04/09 17:24
S95	10	"429"/$.ccls. and battery and electrolyte with vinylidene near2 fluoride same high near2 molecular near2 weight	US-PGPUB; USPAT	OR	ON	2009/04/09 17:24
S96	137	"429"/$.ccls. and battery and electrolyte with vinylidene near2 fluoride with (acrylate methacrylate ether)	US-PGPUB; USPAT	OR	ON	2009/04/09 17:48
S97	4	S95 and S96	US-PGPUB; USPAT	OR	ON	2009/04/09 17:48
S98	0	"20020028389".pn. and electrolyte with solvent near2 includ$4	US-PGPUB; USPAT	OR	ON	2009/04/09 17:51
S99	1	"20020028389".pn. and solvent near2 includ$4	US-PGPUB; USPAT	OR	ON	2009/04/09 17:51
S100	3	"429"/$.ccls. and battery and electrolyte with vinylidene near2 fluoride with (acrylate methacrylate ether) with polymeriz$4	US-PGPUB; USPAT	OR	ON	2009/04/09 17:56

S101	0	"429"/$.ccls. and anode with thin near2 filem near4 (silicon si) same (alloy sinter$4)	US-PGPUB; USPAT	OR	ON	2009/04/23 13:49
S102	21	"429"/$.ccls. and anode with thin near2 film near4 (silicon si) same (alloy sinter$4)	US-PGPUB; USPAT	OR	ON	2009/04/23 13:49
S103	42	"429"/$.ccls. and anode with thin near2 film near4 (silicon si)	US-PGPUB; USPAT	OR	ON	2009/04/23 13:50
S104	21	S103 not S102	US-PGPUB; USPAT	OR	ON	2009/04/23 13:50
S105	3	("20020031708" | "20020168572" | "20030054253").PN.	US-PGPUB; USPAT	OR	ON	2009/04/23 13:52
S106	11	"429"/$.ccls. and negative near2 electrode with (silicon si) with (gas near2 phase cvd deposit$4 sinter$4) same alloy near4 current near2 collector	US-PGPUB; USPAT	OR	ON	2009/04/23 13:53
S107	68	"429"/$.ccls. and negative near2 electrode with thin near2 film near4 (silicon si)	US-PGPUB; USPAT	OR	ON	2009/04/23 14:12
S108	68	S107 not S102 not S103	US-PGPUB; USPAT	OR	ON	2009/04/23 14:12
S109	65	S107 and (sinter$4 gas near2 phase liquid near3 phase deposit$4)	US-PGPUB; USPAT	OR	ON	2009/04/23 14:13
S110	52	S107 and silicon with (sinter$4 gas near2 phase liquid near3 phase deposit$4)	US-PGPUB; USPAT	OR	ON	2009/04/23 14:13
S111	99	"429"/$.ccls. not fuel near2 cell and (anode negative near2 electrode) with (silicon si) near3 thin near2 film	US-PGPUB; USPAT	OR	ON	2009/05/11 13:57

S112	73	S111 and (anode negative near2 electrode) with (deposit $4 sinter$4)	US-PGPUB; USPAT	OR	ON	2009/05/11 13:58
S113	32	"429"/$.ccls. not fuel near2 cell and (anode negative near2 electrode) with (silicon si) near3 thin near2 film with (deposit$4 sinter $4)	US-PGPUB; USPAT	OR	ON	2009/05/11 13:58
S114	7	"429"/$.ccls. not fuel near2 cell and (anode negative near2 electrode) with (silicon si) near3 thin near2 film same (deposit$4 sinter $4) not S113	US-PGPUB; USPAT	OR	ON	2009/05/11 14:04

5/11/2009 3:02:46 PM
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